Lecture #8. Fall, 2012 Electrochemical Energy Engineering

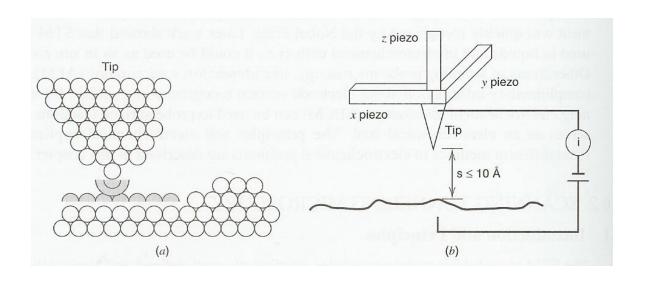
Scanning probe techniques (ch. 16)

Scanning tunneling microscopy (STM)
Atomic force microscopy (AFM)
Scanning electrochemical microscopy (SECM)

Scanning probe techniques

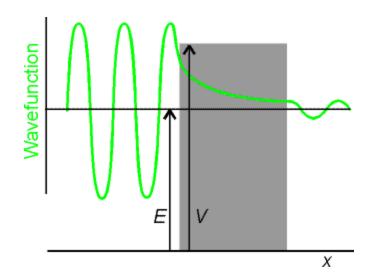
Microscopy: optical \rightarrow scanning electron or force \rightarrow STM, AFM in situ vs. ex situ techniques

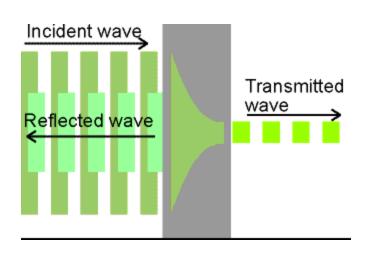
Scanning tunneling microsocpy (STM)

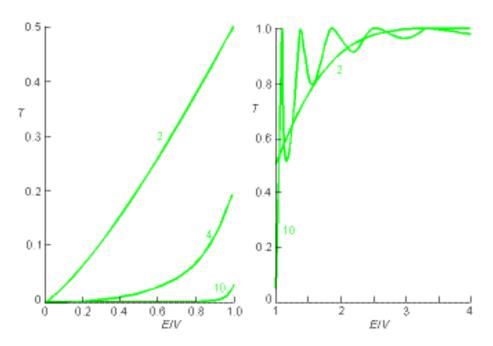


Tunnelling

- if the potential energy of a particle does not rise to infinite in the wall & E < V \rightarrow Ψ does not decay abruptly to zero
- if the walls are thin $\rightarrow \Psi$ oscillate inside the box & on the other side of the wall outside the box \rightarrow particle is found on the outside of a container: leakage by penetration through classically forbidden zones "tunnelling"
- cf) C.M.: insufficient energy to escape



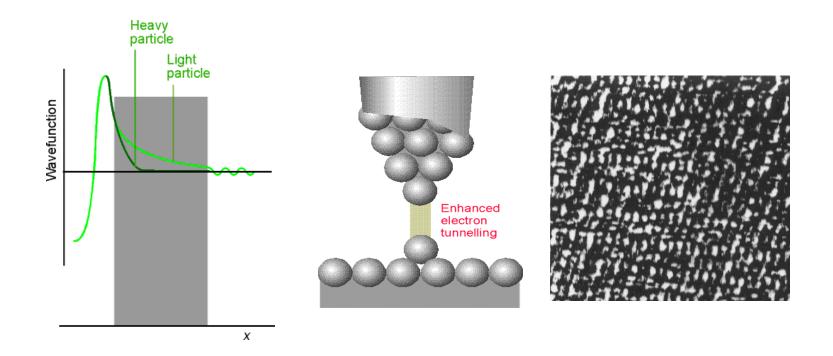




The transition probabilities for passage through a barrier. The horizontal axis is the energy of the incident particle expressed as a multiple of the barrier height. The curves are labelled with the value of $L(2mV)^{1/2}/$. The graph on the left is for E < V and that on the right for E > V. Note that T = 0 for E < V whereas classically T would be zero. However, T < 1 for E > V, whereas classically T would be 1.

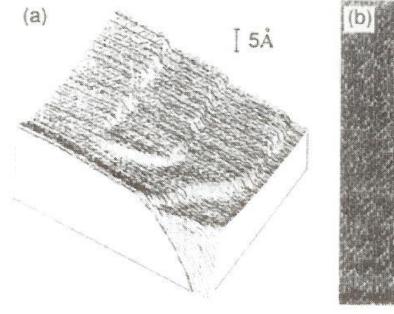
enhanced reflection (antitunnelling)

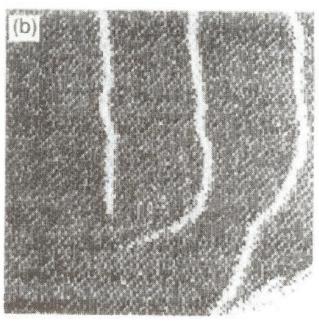
- high, wide barrier $\kappa L >> 1$
 - \Rightarrow T decrease exponentially with thickness of the barrier, with m^{1/2}
 - ⇒ low mass particle → high tunnelling *tunnelling is important for electron



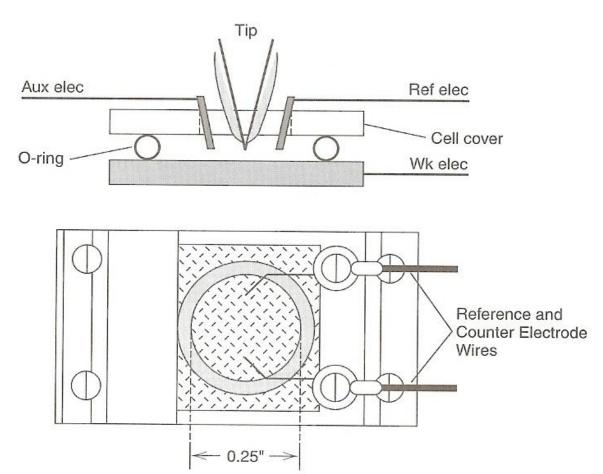
e.g) proton transfer reaction
STM (scanning tunnelling microscopy)
AFM (atomic force microscopy)

Au(111) at 0.7 V vs. NHE in HCl

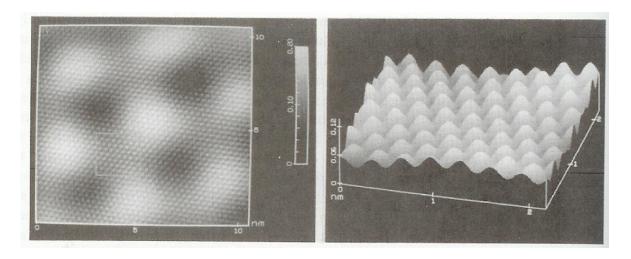




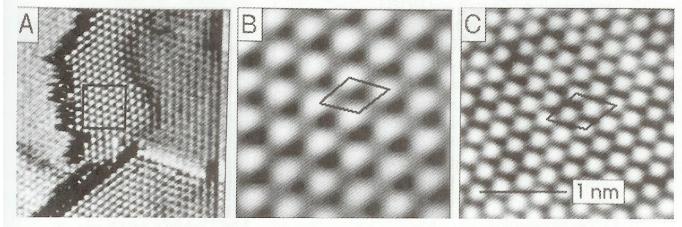
Electrochemical STM



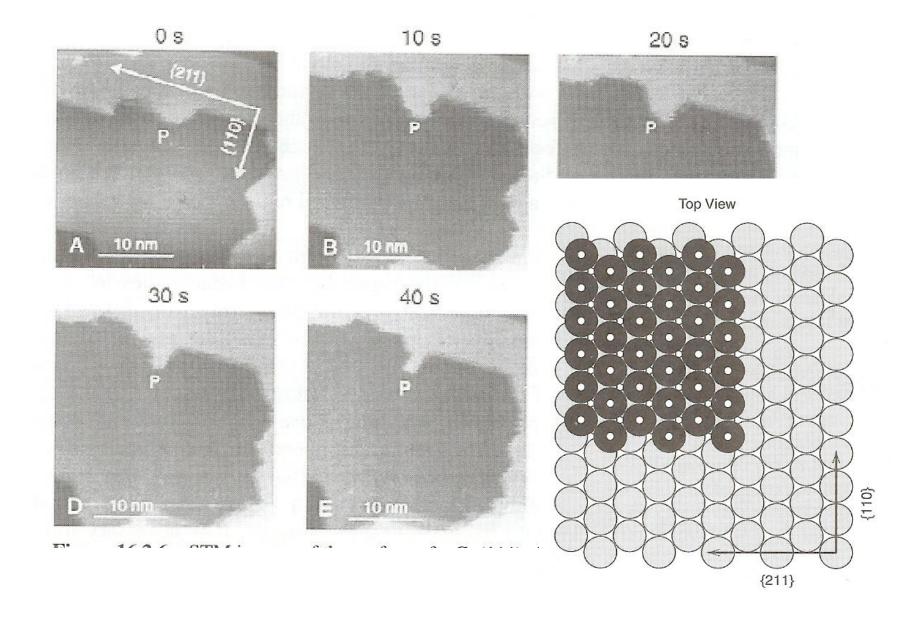
STM images of HOPG

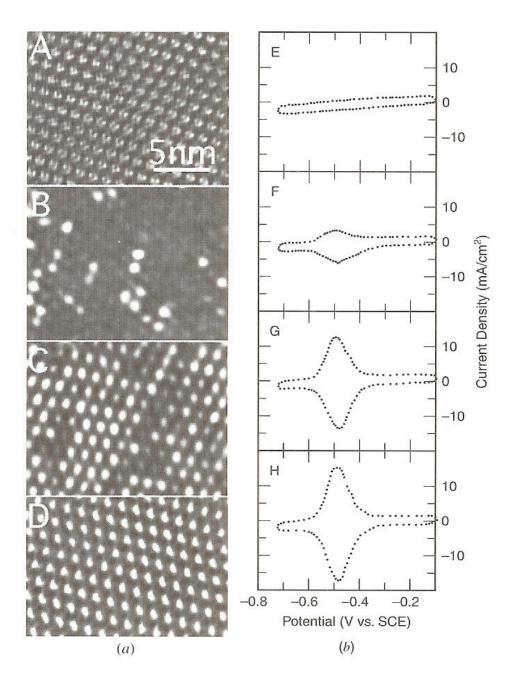


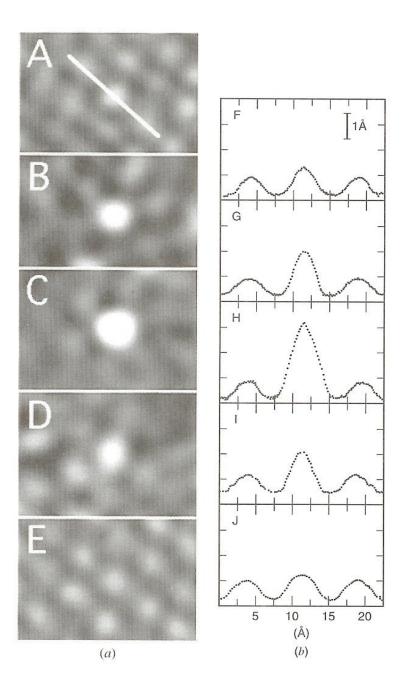
STM images of Pt(111) with I-adlattice in HClO₄



STM images of Cu(111): effect of etching

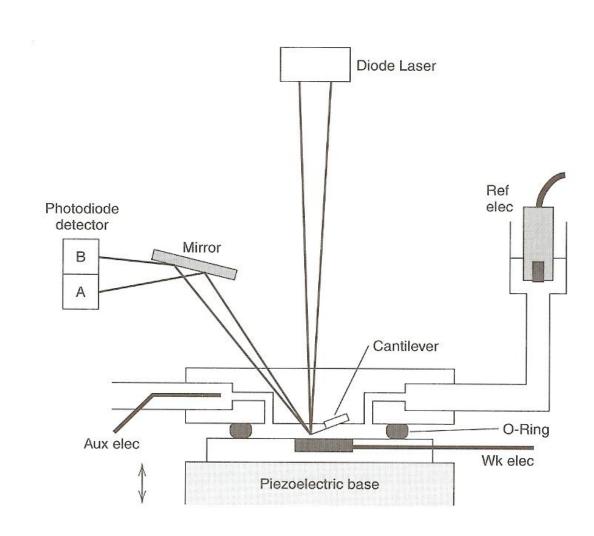




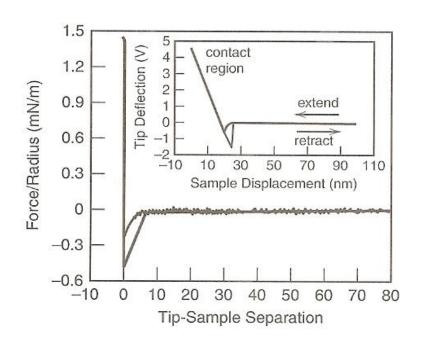


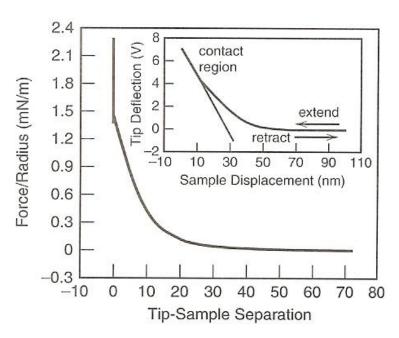
Scanning tunneling spectroscopy (STS)

Atomic force microscopy (AFM)



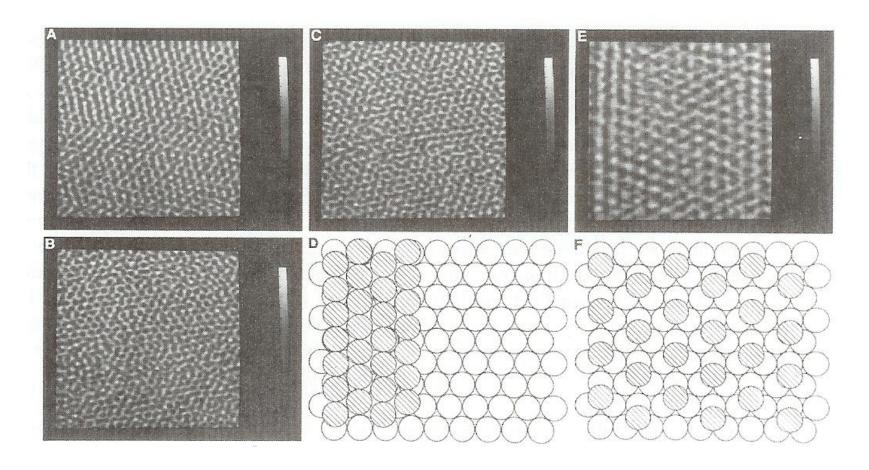
Cantilever displacement vs. z-deflection for (left) attractive interaction and (right) repulsive interaction



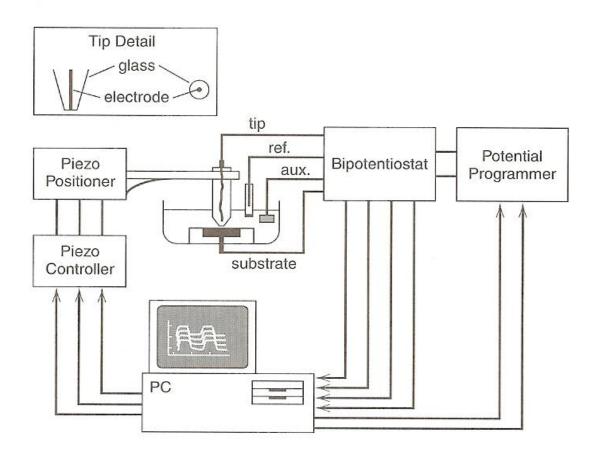


Electrochemical AFM

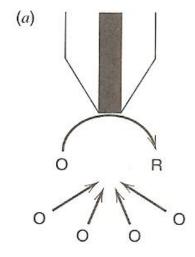
AFM of Cu underpotential deposition (UPD) on Au(111)



Scanning electrochemical microscopy (SECM)

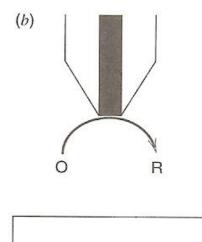


Principles of SECM

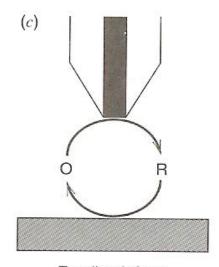


Hemispherical Diffusion

 $i_{\mathsf{T},\infty} = 4\mathsf{nFDCa}$

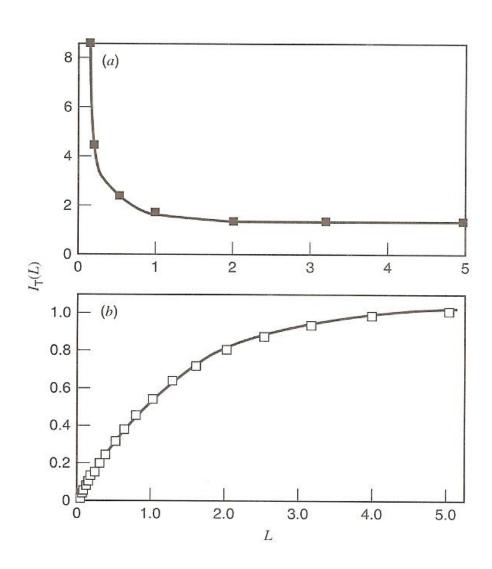


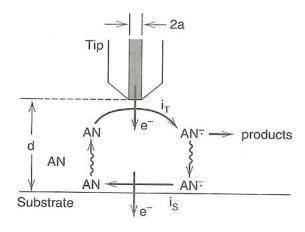
Blocking by Insulating Substrate $i_{\rm T} < i_{\rm T,\infty}$

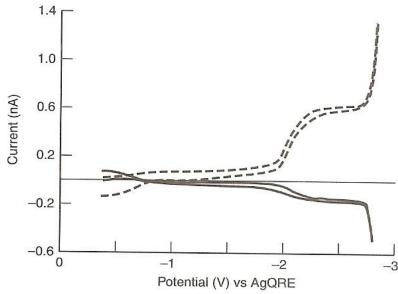


Feedback from Conductive Substrate $i_{\rm T} > i_{\rm T,\infty}$

SECM appoach curves for steady-state currents

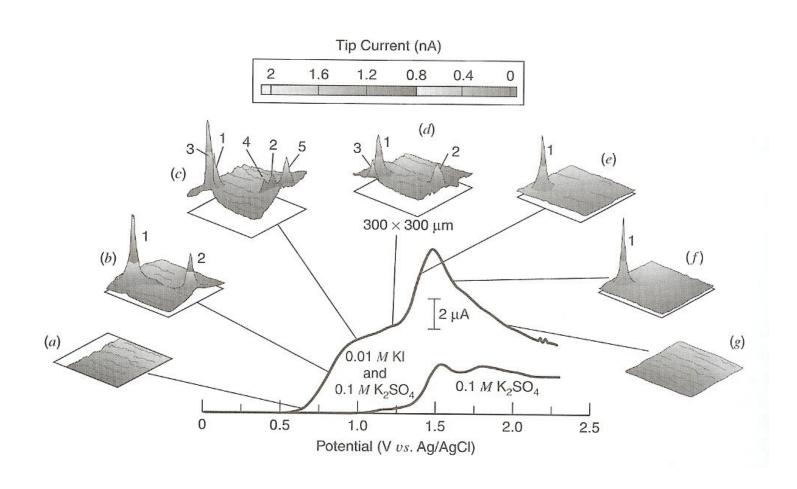


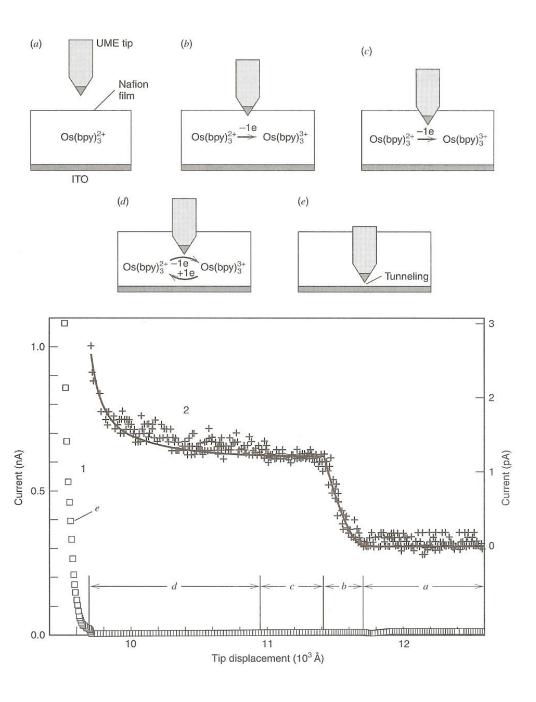




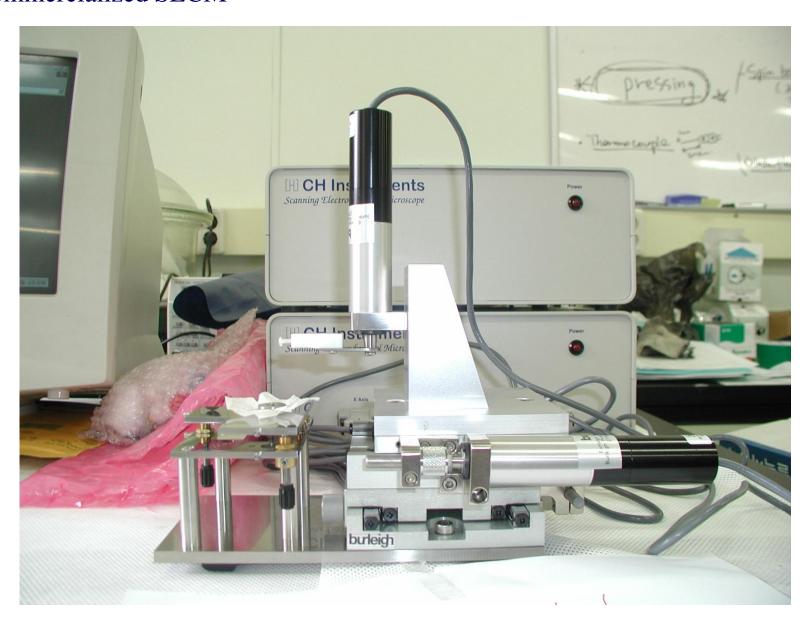
Imaging surface topography & reactivity

Ta oxide formation on Ta

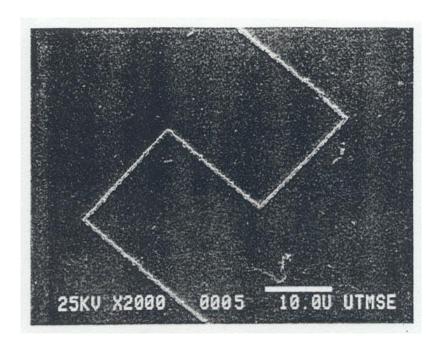




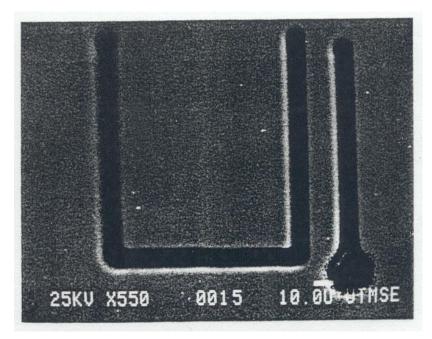
Commercialized SECM



SECM applications



Ag line formation



Electrochemical Cu etching